IN THE CLAIMS:

This amendment is made in the 25 February 2003 Revised Format:

- 1 (Currently Amended) A thermal barrier coating
- 2 comprising a layer of rare-earth element phosphate said layer having a
- 3 thickness greater than about 20 micrometers, a thermal conductivity less
- 4 than about 2 W/mK and disposed on an exterior surface of a substrate so as
- 5 to thermally protect the substrate.



- (Original Claim) The thermal barrier coating according
 to Claim 1 further comprising a monazite or xenotime crystal structure.
- 1 3. (Original Claim) The thermal barrier coating according
- 2 to Claim 1, wherein the ratio between rare-earth element and phosphate is
- 3 about 1:1.
- 1 4. (Currently Amended) The thermal barrier coating
- 2 according to Claim 1, wherein the layer has having a thickness between 10-
- 3 about 20 and 500 micrometers.
- 1 5. (Original Claim) The thermal barrier coating according
- 2 to Claim 1 deposited on a substrate having a temperature between 600°C
- 3 and 1100°C.
- 1 6. (Original Claim) The thermal barrier coating according
- 2 to Claim 5 deposited on a substrate having a temperature between 750°C
- 3 and 950°C.

7. (Original Claim) The thermal barrier coating according to Claim 1 formed by a process selected from the group consisting of chemical vapor deposition, physical vapor deposition, electron beam evaporation, pulsed electron beam evaporation, laser ablation, and plasma spraying.

1 8. (Original Claim) The thermal barrier coating according 2 to Claim 7 using single or multiple sources of materials selected from the 3 group consisting of rare-earth phosphates and mixtures of rare-earth 4 precursors with phosphorous precursors.

9. (Original Claim) The thermal barrier coating according to Claim 1 formed with a columnar microstructure.

1 10. (Original Claim) The thermal barrier coating according 2 to Claim 1 formed with a porous microstructure.

1 11. (Original Claim) The thermal barrier coating according to Claim 1, wherein the phosphate is lanthanum phosphate.

1 12. (Original Claim) The thermal barrier coating according 2 to Claim 1 deposited on one of a ceramic substrate and a metallic substrate.

13. (Currently Amended) The thermal barrier coating according to Claim 12, wherein the metal_metallic substrate is a nickel-based superalloy, an iron-based superalloy or a cobalt-based superalloy.

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1 14. (Currently Amended) The thermal barrier coating 2 according to Claim 13 further comprising a layer of aluminum phosphate 3 disposed between the <u>layer of rare-earth element phosphate and the metal-4 metallic substrate.</u>

15. (Original Claim) The thermal barrier coating according
 2 to Claim 13 further comprising a layer of alumina between the metallic
 3 substrate and said rare-earth element phosphate.

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16. (Original Claim) The thermal barrier coating according
 2 to Claim 15 further comprising a region of rare-earth aluminate between the
 3 alumina and said rare-earth element phosphate.

1 17. (Original Claim) The thermal barrier coating according 2 to Claim 1 comprising a mixture of lanthanum phosphate, cerium phosphate

3 and neodymium phosphate.

1 18. (Currently Amended) A thermal barrier coating
2 comprising a layer of lanthanum phosphate said layer having a thickness
3 greater than about 20 micrometer and disposed on an exterior surface of a
4 substrate so as to thermally protect the substrate.

19. (Original Claim) The thermal barrier coating according
 to Claim 18 further comprising a monazite crystal structure.

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- 1 20. (Original Claim) The thermal barrier coating according
- 2 to Claim 18, wherein the ratio between lanthanum and phosphate is about
- 3 1:1.
- 1 21. (Currently Amended) The thermal barrier coating
- 2 according to Claim 18, wherein the layer has having a thickness between 10-
- 3 about 20 and 500 micrometers.
- 1 22. (Original Claim) The thermal barrier coating according
- 2 to Claim 18 deposited on a substrate having a temperature between 600°C
- 3 and 1100°C.
- 1 23. (Original Claim) The thermal barrier coating according
- 2 to Claim 22 deposited on a substrate having a temperature between 750°C
- 3 and 950°C.
- 1 24. (Original Claim) The thermal barrier coating according
- 2 to Claim 18 formed by a process selected from the group consisting of
- 3 chemical vapor deposition, physical vapor deposition, electron beam
- 4 evaporation, pulsed electron beam evaporation, laser ablation, and plasma
- 5 spraying.
- 6 25. (Original Claim) The thermal barrier coating according
- 7 to Claim 24 using single or multiple sources of materials selected from the
- 8 group consisting of rare-earth phosphates and mixtures of rare-earth
- 9 precursors with phosphorous precursors.

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- 1 26. (Original Claim) The thermal barrier coating according 2 to Claim 18 formed with a columnar microstructure.
- 1 27. (Original Claim) The thermal barrier coating according 2 to Claim 18 formed with a porous microstructure.
- 1 28. (Original Claim) The thermal barrier coating according 2 to Claim 18 deposited on one of a ceramic substrate and a metallic 3 substrate.
- 1 29. (Currently Amended) The thermal barrier coating 2 according to Claim 28, wherein the metal-metallic substrate is a nickel-based 3 superalloy, an iron-based superalloy or a cobalt-based superalloy.
- 30. (Currently Amended) The thermal barrier coating according to Claim 29 further comprising a layer of aluminum phosphate disposed between the <u>layer of lanthanum phosphate</u> and the <u>metal-metallic</u> substrate.
- 1 31. (Original Claim) The thermal barrier coating according 2 to Claim 29 further comprising a layer of alumina between the metallic 3 substrate and the lanthanum phosphate.
- 32. (Original Claim) The thermal barrier coating according
 to Claim 31 further comprising a region of lanthanum aluminate between the lanthanum phosphate.

- 1 33. (Original Claim) The thermal barrier coating according 2 to Claim 18 comprising a mixture of lanthanum phosphate, cerium 3 phosphate and neodymium phosphate.
- 1 34. (Currently Amended) thermal barrier coating 2 comprising a <u>layer of a</u> mixture of rare-earth element phosphates and 3 refractory oxides said layer having a thickness greater than about 20 4 micrometers, a thermal conductivity less than about 2 W/mK and disposed 5 on an exterior surface of a substrate so as to thermally protect the 6 substrate.
- 1 35. (Currently Amended) The thermal barrier coating 2 according to Claim 34, wherein the layer has having a thickness between 10-3 about 20 and 500 micrometers.
- 1 36. (Original Claim) The thermal barrier coating according 2 to Claim 34 deposited on a substrate having a temperature between 600°C and 1100°C.
- 1 37. (Original Claim) The thermal barrier coating according 2 to Claim 34 formed by a process selected from the group consisting of 3 chemical vapor deposition, physical vapor deposition, electron beam 4 evaporation, pulsed electron beam evaporation, laser ablation, and plasma 5 spraying.

- 6 38. (Original Claim) The thermal barrier coating according 7 to Claim 34 formed with a columnar microstructure.
- 1 39. (Original Claim) The thermal barrier coating according 2 to Claim 34 formed with a porous microstructure.
- 1 40. (Original Claim) The thermal barrier coating according 2 to Claim 34 deposited on one of a ceramic substrate and a metallic 3 substrate.
- 1 41. (Currently Amended) The thermal barrier coating 2 according to Claim 40, wherein the metal-metallic substrate is a nickel-based 3 superalloy, an iron-based superalloy or a cobalt-based superalloy.
- 1 42. (Currently Amended) The thermal barrier coating 2 according to Claim 41 further comprising a layer of aluminum phosphate 3 disposed between the mixture and the metal metallic substrate.
- 1 43. (Original Claim) The thermal barrier coating according 2 to Claim 41 further comprising a layer of alumina between the metallic 3 substrate and the mixture.